

The Two-Channel Transistor for Low-Energy Applications

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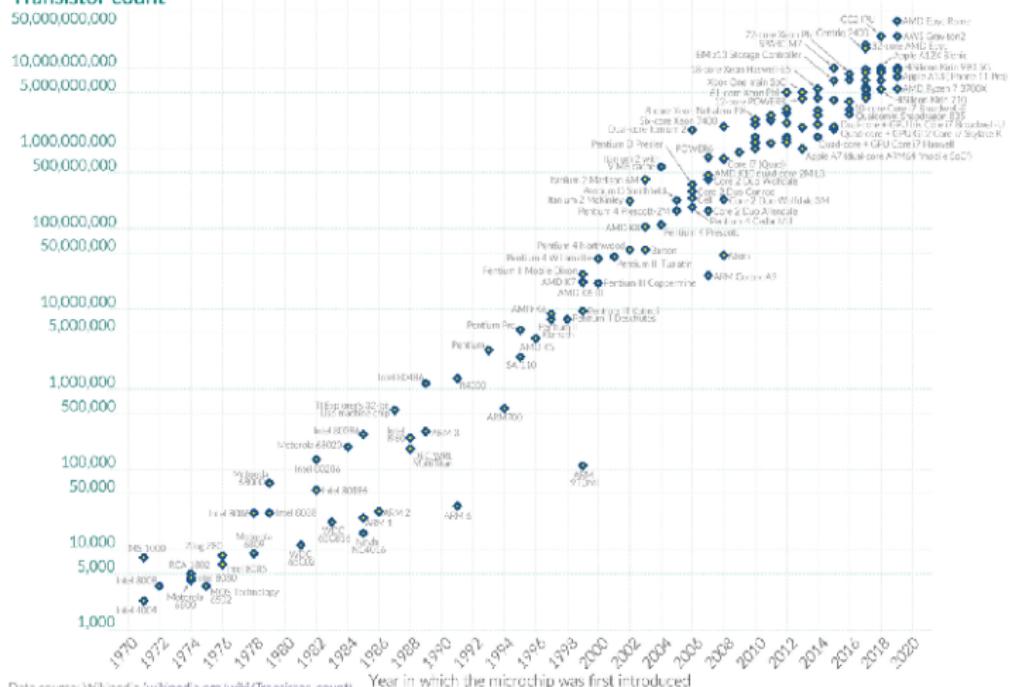
⁴Wiatec; Fichtenstraße 6, 01097 Dresden, Germany

A presentation on the Photonics Days 2023
Berlin, 10.10.2023

Moore's Law: The number of transistors on microchips doubles every two years

Moore's law describes the empirical regularity that the number of transistors on integrated circuits doubles approximately every two years. This advancement is important for other aspects of technological progress in computing – such as processing speed or the price of computers.

Transistor count



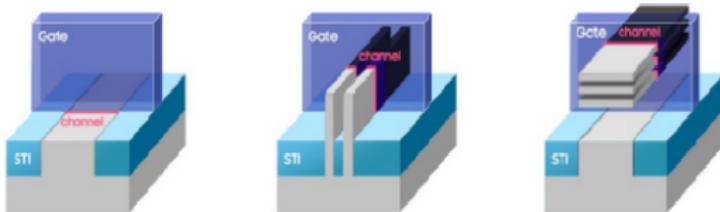
Data source: Wikipedia (https://en.wikipedia.org/wiki/Transistor_count)

OurWorldInData.org – Research and data to make progress against the world's largest problems.

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Source: Wikipedia

Changing transistor architectures for Moore's law



MOSFET

FinFET

nanosheet transistor
MBCFET



~22nm, 2011



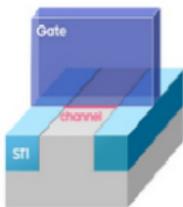
3nm, 2022

microelectronics

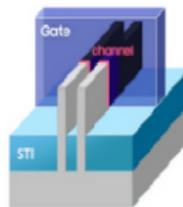
nanoelectronics

atomar electronics?

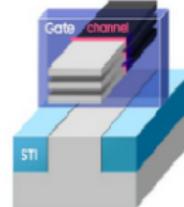
Samsung: '3nm GAA MBCFET: Unrivaled SRRAM Flexibility' Jun 21, 2023



MOSFET



FinFET



nanosheet transistor
MBCFET

alternative

SOI transistor

Two-channel transistor

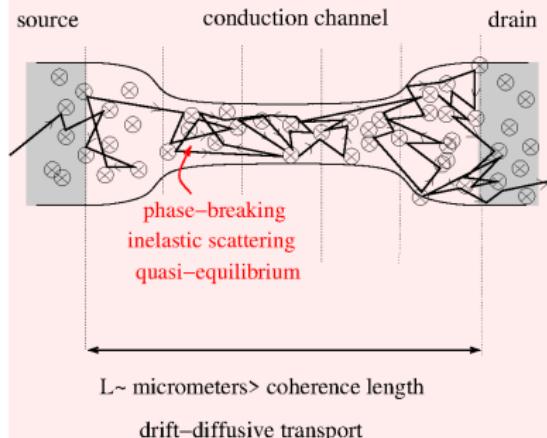
22FDX, Globalfoundries, Dresden

resonant tunneling

low-energy applications

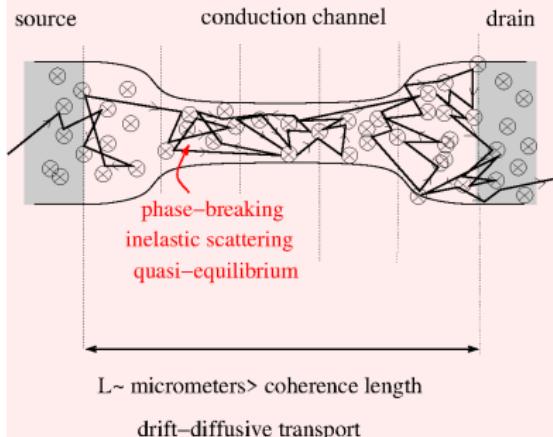
Semiclassical transport vs. Quantum transport

semiclassical transport for microelectronics

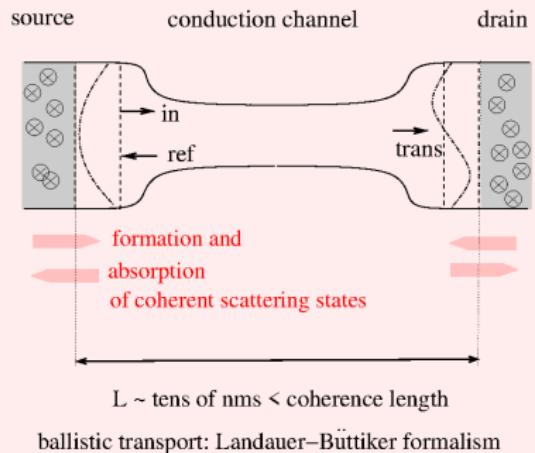


Semiclassical transport vs. Quantum transport

semiclassical transport for microelectronics



quantum transport for nanoelectronics



Article

A One-Dimensional Effective Model for Nanotransistors in Landauer–Büttiker Formalism

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2. Application to nano-MOSFETs: Mathematics 2017, 5, 68

Article

Channel Engineering for Nanotransistors in a Semiempirical Quantum Transport Model

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and Jan Höntsche⁴

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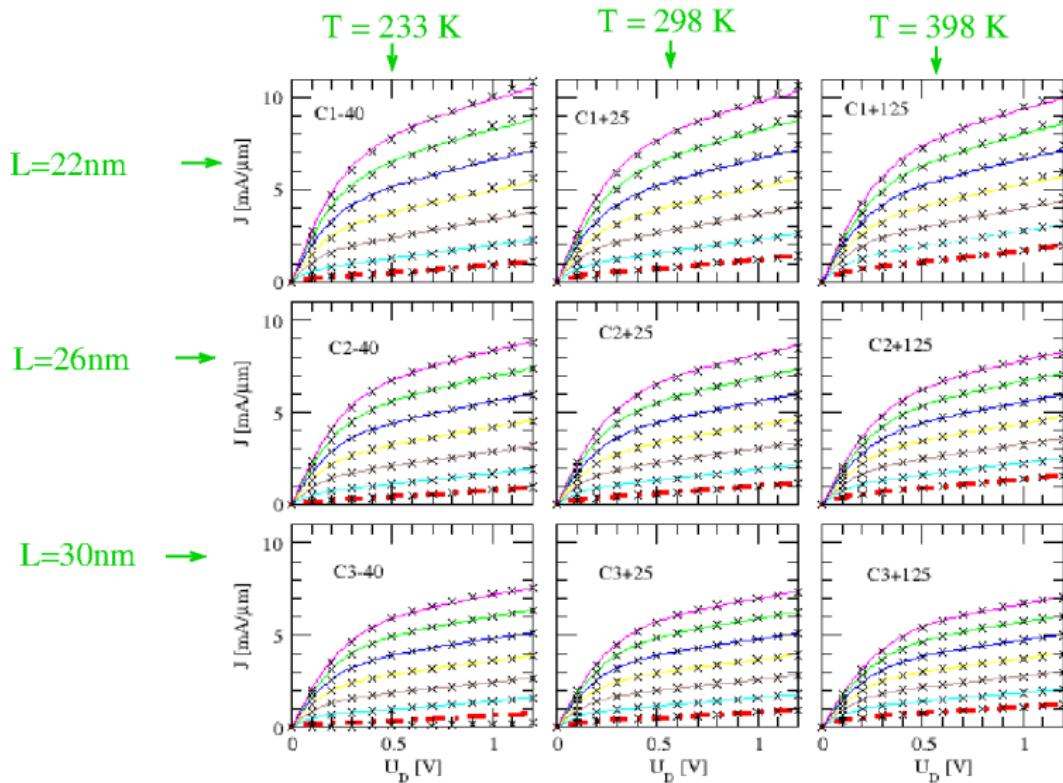
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15236 Frankfurt (Oder), Germany

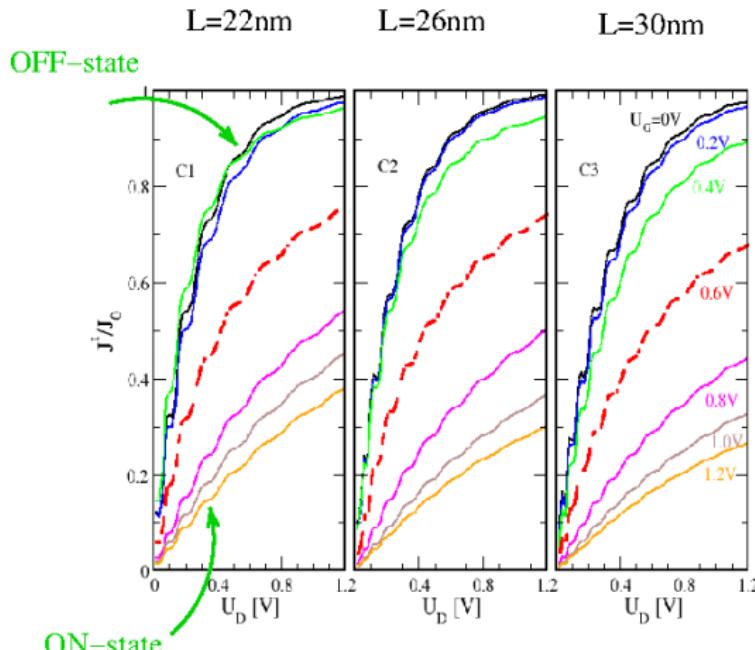
⁴ GlobalFoundries Dresden, Wilschdorfer Landstraße 101, 01109 Dresden, Germany;
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Output characteristics of nano-MOSFETs: Theory and experiment



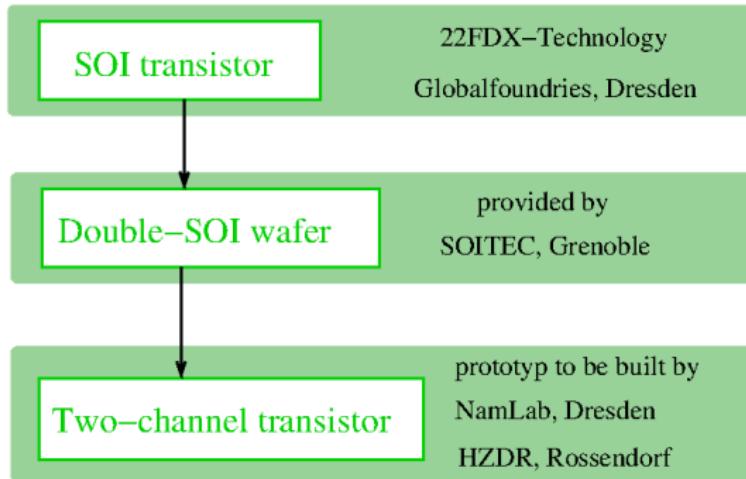
Ratio between tunneling current and total current



On the minus side: marked tunneling decreases gate control !!!

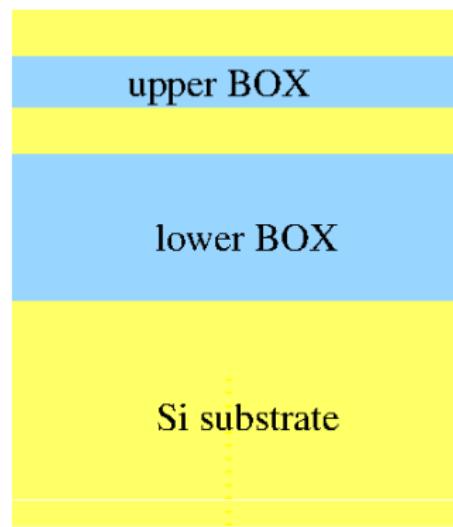
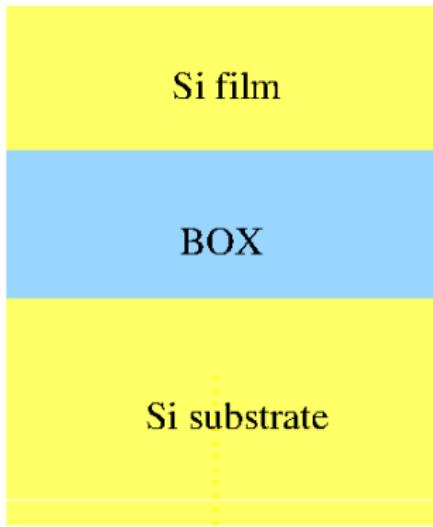
On the plus side

Tunneling as new device concept: Two channel transistor

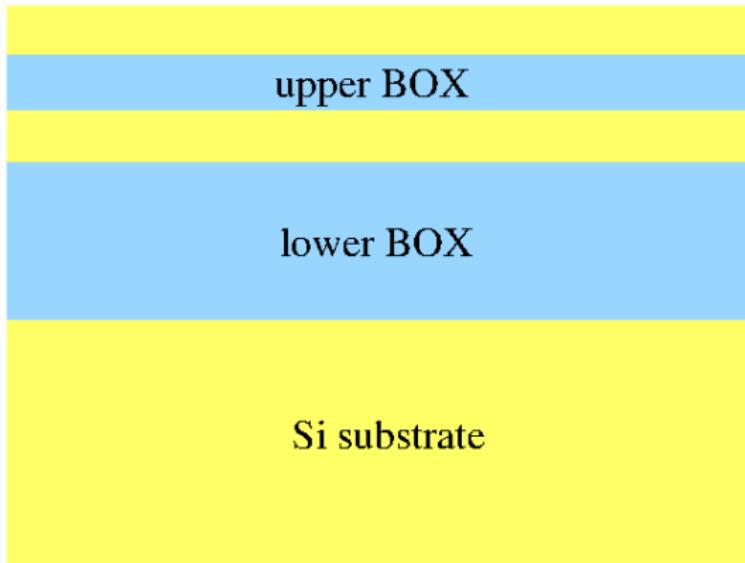


From SOI-wafer to double-SOI wafer

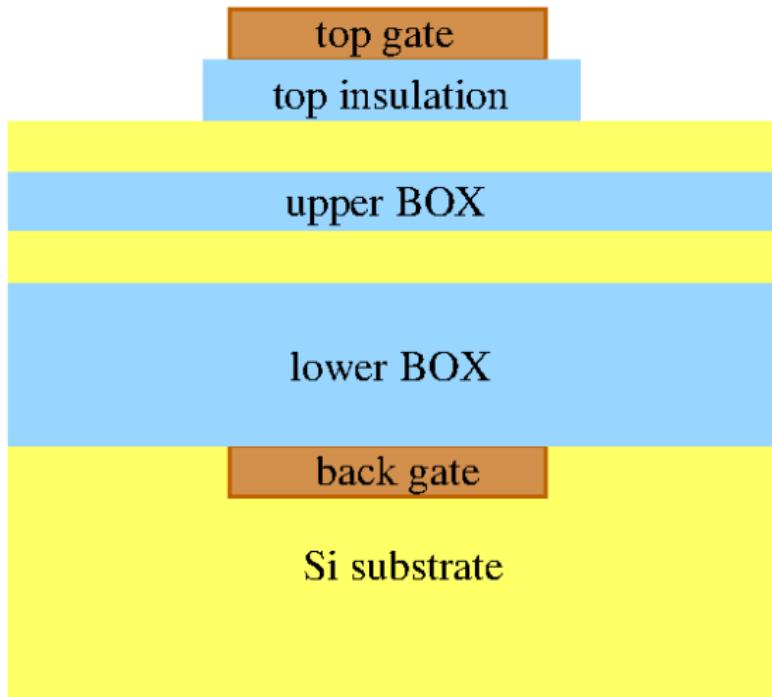
SOI wafer \longrightarrow double SOI
from SOITEC (LOI)



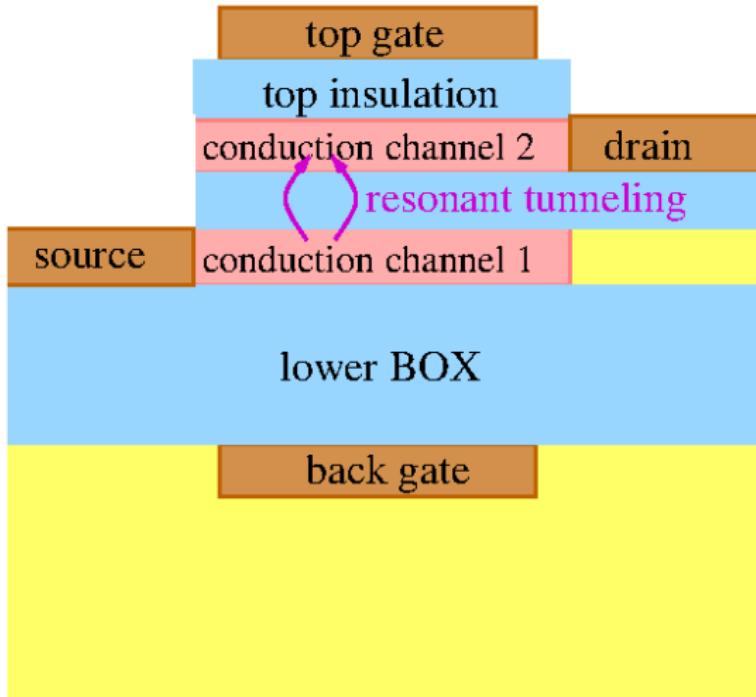
From double-SOI wafer to two-channel transistor



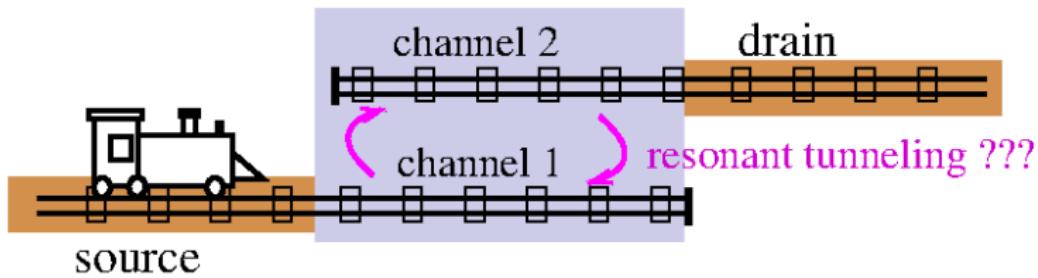
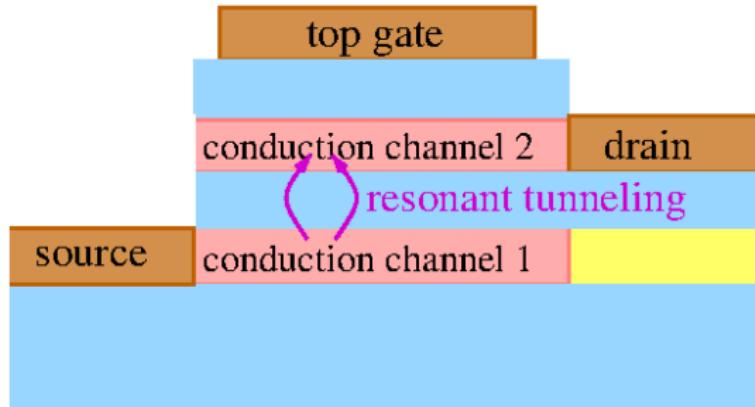
start with standard SOI-technology:

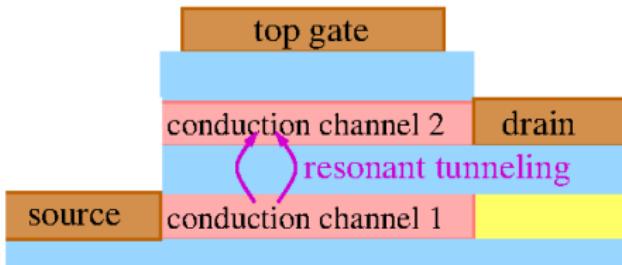


add selective source/drain contacts

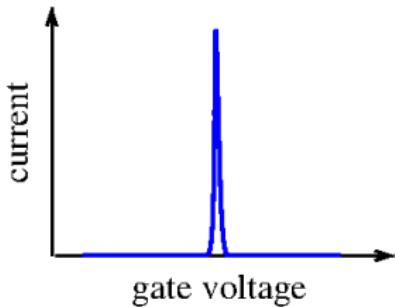


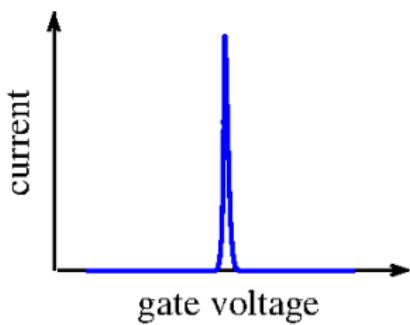
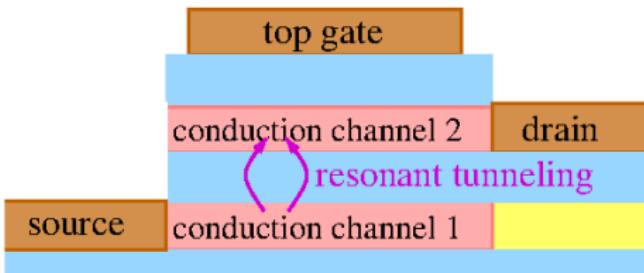
functionality of the two-channel transistor



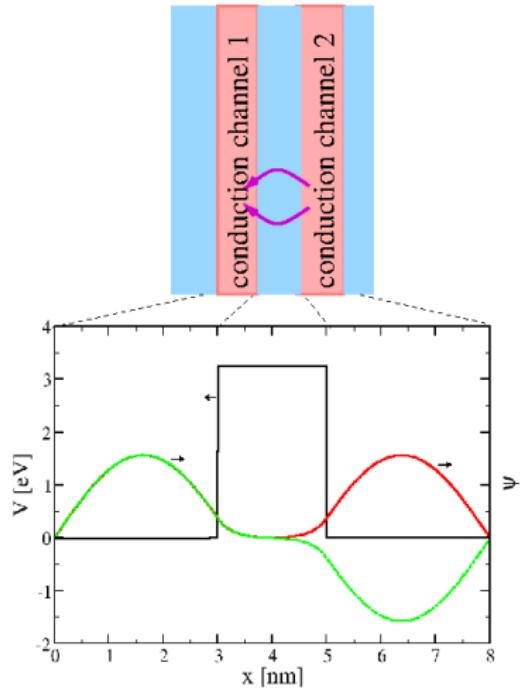


microscopic:
resonant tunneling peak at particular gate voltages





- small gate voltage ON/OFF
- low voltage / low energy
- thermal stability
- electrical engineering CMOS-concept talk by G. Teepe at Photonics Days 2022
- Low temperature tunneling peak found in microscale GaAs Heterostructures
(J. A. Simmons, J. Appl. Phys. 84, 5626 (1998))



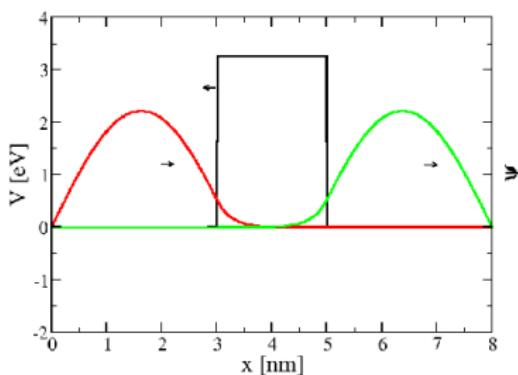
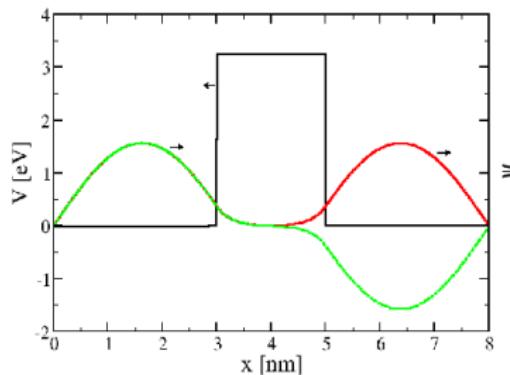
dependence on transverse voltage = control voltage

$$\delta U = 0$$

symmetrical potential

$$\delta U = 50 \text{ mV}$$

asymmetrical potential



Conclusions / happy ending:

- ▶ Hope that I have convinced you that the two-channel transistor is an interesting device concept that should be given a chance.
- ▶ Best thanks for your attention !!